

	Hit s	Search Text	DBs
15	0	<p>((organic or polymer\$4 or polyimide or polyamide or photoresist or resist) near22 (conduct\$4 or electroconductive or semiconduct\$4 or transistor)) same (dop\$4 or implant\$4 or infus\$3) same (irradiat\$4 or expos\$4 or illuminat\$4) same ((electron near9 beam) or e\$3beam or UV or IR or DUV or EUV or excimer or laser or light or radiation) and (((dop\$4 or implant\$6 or infus\$4) near22 (UV or irradiat\$4 or radiation or expos\$4)) same (interconnect\$4 or ((organic or polymer\$3 or region) near19 (interconnect or connect\$4 or contact\$4))) same source same drain) and ((remov\$4 or eliminat\$4 or dissipat\$\$ or rid or bounce) near18 (unbounded or mobile or loose\$3 or (weak near9 (implant or dop\$4))) near29 (((temperature or heat\$3 or bak\$4 or anneal) near4 (high\$3 or elevat\$4 or ris\$3)) or ((reduc\$4 or vacuum or evacuu\$5) near3 (pressure or torr or atmosphere))))</p>	US - PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
16	0	((remov\$4 or eliminat\$4 or dissipat\$\$ or rid or bounce) near18 (((unbounded or mobile or loose\$3) near8 (implant\$4 or dop\$4)) or (weak near9 (implant or dop\$4))) near29 (((temperature or heat\$3 or bak\$4 or anneal) near4 (high\$3 or elevat\$4 or ris\$3)) or ((reduc\$4 or vacuum or evacuu\$5) near3 (pressure or torr or atmosphere)))) and (((organic or polymer\$4 or polyimide or polyamide or photoresist or resist) near22 (conduct\$4 or electroconductive or semiconduct\$4 or transistor)) same (dop\$4 or implant\$4 or infus\$3) same (irradiat\$4 or expos\$4 or illuminat\$4) same ((electron near9 beam) or e\$3beam or UV or IR or DUV or EUV or excimer or laser or light or radiation))	US - PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
17	11	((remov\$4 or eliminat\$4 or dissipat\$\$ or rid or bounce or strip\$\$) near18 (((unbounded or mobile or loose\$3 or peripher\$5 or surface) near8 (implant\$4 or dop\$4)) or (weak near9 (implant or dop\$4))) near29 ((temperature or heat\$3 or bak\$4 or anneal) near4 (high\$3 or elevat\$4 or ris\$3)) or ((reduc\$4 or vacuum or evacuu\$5) near 3 (pressure or torr or atmosphere))) and (((organic or polymer\$4 or polyimide or polyamide or photoresist or resist) near22 (conduct\$4 or electroconductive or semiconduct\$4 or transistor)) same (dop\$4 or implant\$4 or infus\$3))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
18	101	((remov\$4 or eliminat\$4 or dissipat\$\$ or rid or bounce or strip\$\$) near18 (((unbounded or mobile or loose\$3 or peripher\$5 or surface or (low near3 diffus\$5)) near8 (implant\$4 or dop\$4)) or (weak near9 (implant or dop\$4))) near29 ((temperature or heat\$3 or bak\$4 or anneal) or ((reduc\$4 near4 pressure) or vacuum or evacuu\$5))) and (((organic or polymer\$4 or polyimide or polyamide or photoresist or resist) near22 (conduct\$4 or electroconductive or semiconduct\$4 or transistor)) same (dop\$4 or implant\$4 or infus\$3))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
19	90	S18 NOT S17	US - PGPUB ; USPAT ; FPRS ; EPO ; JPO ; DERWENT ; IBM_TDB
20	46	((organic or polyimide or photoresist) near16 (semiconduct\$4 or conduct\$4) near22 (dop\$3 or implant\$4 or infus\$4) near16 contact\$4 near9 source near12 drain near9 electrode)	US - PGPUB ; USPAT ; FPRS ; EPO ; JPO ; DERWENT ; IBM_TDB
22	38	((organic or polyimide) near16 (semiconduct\$4 or conduct\$4) near22 (dop\$3 or implant\$4 or infus\$4) near26 contact\$4 near20 source near16 drain)	US - PGPUB ; USPAT ; FPRS ; EPO ; JPO ; DERWENT ; IBM_TDB